

**REMARKS/ARGUMENT**

The Examiner's indication that claim 2 would be allowable in independent form has been noted with appreciation. The applicant is satisfied with claims of that scope and has therefore combined claims 1 and 2. As a result of this amendment, it is respectfully submitted that all claims are now in condition to be allowed and the early issuance of a Notice of Allowance is respectfully solicited.

Respectfully submitted,



Edward A. Meilman  
Registration No.: 24,735  
DICKSTEIN SHAPIRO MORIN & OSHINSKY, LLP  
1177 Avenue of the Americas  
New York, New York 10036  
Telephone: (212) 835-1400

EAM:hg

**APPENDIX A**  
**Version With Markings To Show Changes Made**  
**37 C.F.R. § 1.121(b)(1)(iii) AND (c)(1)(ii)**

**CLAIMS:**

1. An electric device comprising:
  - a substrate;
  - a lower electrode layer on the substrate and comprising a material capable of reactive-ion etching with a fluorine-based gas which is at least one element selected from the group consisting of Si, Mo, W, B, C, S and Ta; and
  - an upper electrode layer on the lower electrode layer and comprising a material capable of reactive-ion etching with a chlorine-based gas, wherein said upper electrode comprises Al.
  
3. An electronic device according to Claim [2] 1, wherein the lower electrode has a thickness of about 0.5 nm to 1000 nm.